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09/940665  
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	Subclass	ISSUE CLASSIFICATION
Class		

PATENT NUM

## U.S. UTILITY Patent Application

O.I.P.E. <i>lsp</i> SCANNED	PATENT DATE <i>TR4 Q.A Am</i>
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APPLICATION NO. 09/940665	CONT/PRIOR F	CLASS 438 439	SUBCLASS 270.1	ART UNIT /752 2812 SGB	EXAMINER CLARKE
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APPLICANTS

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TITLE

Chemically amplified resist composition and method for forming  
Patterned film using same

PTR  
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## ISSUING CLASSIFICATION

ORIGINAL		CROSS REFERENCE(S)						
CLASS	SUBCLASS	CLASS	SUBCLASS (ONE SUBCLASS PER BLOCK)					
INTERNATIONAL CLASSIFICATION								
<input type="checkbox"/> Continued on Issue Slip Inside File Jacke								

TERMINAL DISCLAIMER	DRAWINGS			CLAIMS ALLOWED	
	Sheets Drwg.	Figs. Drwg.	Print Fig.	Total Claims	Print Claim ft
<input type="checkbox"/> The term of this patent subsequent to _____ (date) has been disclaimed.	(Assistant Examiner) _____ (Date) _____			NOTICE OF ALLOWANCE MAIL	
<input type="checkbox"/> The term of this patent shall not extend beyond the expiration date of U.S Patent. No. _____ _____	(Primary Examiner) _____ (Date) _____			ISSUE FEE	
<input type="checkbox"/> The terminal _____ months of this patent have been disclaimed.	(Legal Instruments Examiner) _____ (Date) _____			ISSUE BATCH NUMBER	

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